THERMAL AND PHOTOLYTIC STABILITIES OF PERFLUOROALKANE SULFONIC ACIDS AND THEIR DERIVATIVES

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The use of perfluoroalkanesulfonic acids and their derivatives in drastic conditions leads us to study their behaviour with respect to temperature and radiative factors.

Such acids as CF₃SO₃H and C₂F₅SO₃H, used in a pure state as well as their related pure anhydride are stable until they reach a temperature of at least 180°C.

On the other hand, the solutions of anhydride with its related acid, yield perfluorosulfonic esters and $\rm SO_2$ at room temperature already:

$$(R_{\mathbf{F}}SO_2)_2O$$
 $\xrightarrow{\mathbf{A}}$ $R_{\mathbf{F}}SO_3H$ $R_{\mathbf{F}}SO_3R_{\mathbf{F}}$ + SO_2

This mechanism is discussed.

These results involve a new and easy synthesis of symmetrical perfluorosulfonic esters $\rm R_FSO_3R_F$ with acids and $\rm P_2O_5$.

Further more, it occurs no transformation of the anhydride under UV and visible irradiation. But under the same conditions, a small account of acids are deshydrated into anhydrides.

A further experiment combining both effects of temperature and light leads to the esters.